

Synthesis and Property Characterization of the MXenes

by

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ABSTRACT

Nanomaterials redefine the lens through which the world is viewed today. The miniaturization of devices and systems to the nanoscale explodes the realm of what is possible as the interactions with neighboring atoms and molecules increase. This interactivity creates ripple effects that lead to superior mechanical, thermal, electrical, and optical properties that are highly desired across several industries. Two-dimensional (2D) materials are a branch of this family, and the focus of this paper revolves around a recent addition to this category called MXenes. The versatile properties of these 2D nanomaterials have made them unique, as they have the desired performance that can be utilized in several industries, especially energy management, wastewater treatment, and microelectronic devices. Followed by the MAX phase synthesis, hydrofluoric (HF) acid has been the primary etchant utilized to derive these 2D nanoparticles. However, alternative etchants via reactions are desirable to achieve similar selective etching without involving highly toxic HF. Therefore, this study investigated MXene synthesis and applications in 3D printing, followed by the formation of the precursor MAX, an optimized in-situ etching method, and streamlined post-etching processes to maximize 2D MXene yield. The etched powders were then analyzed using scanning electron microscopy (SEM), x-ray diffraction (XRD), atomic force microscopy (AFM), and energy-dispersive x-ray spectroscopy (EDS) characterization methods to verify and validate the MXene dimensions, chemistry, and crystal structures. Simple applications, such as the dispersion feasibility for customizing micropatterns via 3D printing, were also demonstrated as examples. Finally, this research showed the simple processing of 2D MXenes and their potential in structural support, heat dissipation, microelectronics, optical meta-surfaces, and other areas.

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TABLE OF CONTENTS

	Page
LIST OF TABLES	v
LIST OF FIGURES	vi
LIST OF ABBREVIATIONS	viii
CHAPTER	
1 INTRODUCTION	1
Overview	1
Background and Literature Review	5
MAX Phase	5
MXenes.....	8
2 MAX AND MXENE SYNTHESIS	17
Materials	17
MAX Phase Synthesis	18
MXene Synthesis.....	18
Characterizations	19
Results and Discussions	20
3 DEMONSTRATIONS OF MXENE APPLICATIONS.....	23
Materials	23
Characterizations	23
Results and Discussions	24
4 CONCLUSIONS	28
REFERENCES	29

LIST OF TABLES

Table	Page
1. Classifications and Features of Nanomaterials ¹	3
2. Summary of MXenes and Their Synthesis Protocols	14

LIST OF FIGURES

Figure		Page
1.	Schematic Illustration Showcasing Most Common Members of the Two-Dimensional (2D) Materials Family as Follows a) MXenes ² , b) Layered Double Hydroxides (LDHs) ³ , c) Graphene, d) Transition Metal Dichalcogenides (TMDCs), e) Metal-Organic Frameworks (MOFs), f) Hexagonal Boron Nitride (h-BN) ⁴ , g) Covalent-Organic Frameworks (COFs) ⁵ , h) Silicate Clays ⁶ , i) Black Phosphorus ⁷ , j) Oxides. ⁸	4
2.	Elemental Constituents of the MAX Phase with Basic Symbols Used to Distinguish Between Different Components. ⁹	4
3.	Elemental Constituents Are Currently Employed in Literature to Form MXenes. This Group Is More Selective than Those Used in the MAX Phase	8
4.	Process Flowchart Illustrating the Experimental Steps Involved in the Synthesis of MXenes From Elemental Powders of MAX Phase to Colloidal $Ti_3C_2T_x$ -ink Solutions.	17
5.	Characterizations of MAX Phase and MXene Throughout the Synthesis Process. a.) Frontal SEM Micrograph of MAX Phase Showcasing Uniform Surface Morphology and Kink Bands, b – c.) Cross-sectional SEM Imaging of Ti_3AlC_2 at Different Resolutions and Magnifications, d.) Cross-sectional SEM Imaging of Multi-layered $Ti_3C_2T_x$ Illustrating Capacious Spacing Between Layers After Etching, e – f.) Delaminated $Ti_3C_2T_x$ Sheets at Different Resolutions, g ₁ – g ₂ .) AFM Images Depicting Cross-sectional Thickness of a Multi-layered $Ti_3C_2T_x$ Stack along the Horizontal Plane, h.) WAXD Diffraction Patterns of Ti_3AlC_2	

Figure	Page
Before and After Etching Displaying Intensities of MAX Phase and Resulting MXene Respective Phase Angles.	22
6. a – c.) Viscoelastic Properties of 30, 50, 100, and 200 mg mL ⁻¹ Aqueous Ti ₃ C ₂ T _x Ink Solutions, d – e.) Printed Rectilinear and Zig-zag patterns of 100 mg mL ⁻¹ Ti ₃ C ₂ T _x Ink, f.) Conductivity vs Concentration Chart for Aqueous Ink Solutions, g ₁ – g ₂ .) CV Graph Highlighting Electrochemical Properties of Ti ₃ C ₂ T _x – coated Electrode at Multiple Scan Speeds.	27

LIST OF ABBREVIATIONS

0D	Zero-dimensional
1D	One-dimensional
2D	Two-dimensional
AFM	Atomic force microscopy
Al	Aluminum
BN	Boron nitride
BP	Black phosphorus
COF	Covalent-organic framework
DI	Deionized
DMA	Dynamic mechanical analysis
DSC	Differential scanning calorimetry
EDS	Energy-dispersive X-ray spectroscopy
GO	Graphene oxide
HIP	Hot-isostatic pressing
HP	Hot pressing
LDH	Layered doubled hydroxide
MOF	Metal-organic framework
PDS	Pulse discharge sintering
PS	Pressureless synthesis
RPM	Revolutions per minute
SEM	Scanning electron microscope
SHS	Self-sustaining high-temperature synthesis

SPS	Spark plasma sintering
TGA	Thermogravimetric analysis
Ti	Titanium
TiC	Titanium carbide
TMDC	Transition metal dichalcogenide
TMO	Transition metal oxide
WAXD	Wide-angle X-ray diffraction

CHAPTER 1

INTRODUCTION

1.1 Overview

Since the mechanical cleavage from graphite in 2004, graphene has shown the considerable potential of revolutionizing the semiconductor industry,¹ which also attracted massive interest in studying graphene and similar two-dimensional (2D) nanomaterials.^{10,113} The superior properties displayed by 2D nanoparticle families are closely relevant to their dimensions (e.g., smaller than 100 nm), chemistry (e.g., elements and compositions), and crystallization features (e.g., HCP with close packing or gyroids with porosity).^{11–39} For example, the defects will be minimized when the particle size reached the nanoscale, which is essential for nanoparticles to display high intrinsic physical and chemical properties.^{13,15,19,21–23,26,31–33,36} Graphite, a natural-occurring crystalline allotropic form of carbon, is known for its lubrication effects. However, the weak van der Waals forces between the layers lead to mechanical weakness. Graphene, its carbon counterpart with atomic layer thickness, shows mechanical strength, good electrical conductivity, and high optical permeability, among many others.^{11,23,28,30}

Classification of nanomaterials is based on several properties (**Table 1**), such as dimensionality, chemical composition, morphology, and crystallization behavior.^{31–33,37} In this thesis, the focused categorization based on dimensionality will be 2D layered nanoparticles, namely, MXenes. Overall, this study aims to summarize the MXene synthesis methods, pinpoint obstacles commonly faced in the current state of the art and streamline the process by demonstrating the synthesis of titanium carbide-based MXene as an example. Last but not the least, the patterning capability via 3D printing also showed

potential applications in cellular solids, heat dissipation, printed circuit board, and coating optics.

Although the 2D material family is rapidly expanding (**Figure 1**), several members have not yet found industrial applications due to a few technical challenges. For example, there is a limit to the scalability of high-quality graphene layers, such as the high defect density in mechanically-exfoliated graphene or the high cost associated with vapor deposition methods.¹ Besides, single-layer graphene nanomaterials are thermodynamically unstable, and their noncontinuous powder state needs high-resolution nanomanufacturing to prevent oxidation and form high precision.¹ On the other hand, a few contenders have emerged and could rival graphene due to their potential applications and versatility across several industries.¹ MXenes, the subject of this paper, composed of 2D carbides, nitrides, and carbonitrides, are firmly entrenched in the second category. MXenes are a family of two-dimensional (2D) transition metal carbides, nitrides, and carbonitrides with the general formula $M_{n+1}X_nT_x$ ($n=1,2,3$) where M represents the transition metal (usually Ti, Ta, Nb, V, Mo), X can either be C or N and T represents the surface termination groups (-OH, -F, -O).^{1,9,40–66}

Table 1. Classifications and features of nanomaterials¹

Number of Nanoscopic Dimensions	Specific surface area (area per unit volume with r, the radius of the sphere or the cross-section; l, length; w, width; t, thickness)	Categories	Advantages	Typical challenges	Examples	Ref.
0D with an aspect ratio of 1		Nanospheres	Simple assembly features due to uniform dimensions along x/y/z axes	Size control during powder-generation	fullerene, metal nanoballs, inorganic quantum dots, and magnetic and noble metal nanoparticles.	21,31–37,67
1D with an aspect ratio [1, 10 ⁹]	$SSA = 3 / (R * p)$ <i>where SSA = specific surface area, R=avg. particle size, and p = density of the material.</i>	Nanotubes, nanowires, nanowhiskers	Large aspect ratios that can efficiently transfer stress and direct electron/phonon transport	Continuity of in-situ growth or long-range order management for non-continuous powders	Carbon nanotubes, silver nanowires, gold nanowhiskers, carbon nanofibers, zinc oxide nanorods, and polymer nanofilaments	
2D with an aspect ratio of [1, ∞]		Nanosheets, nanoplatelets, nanolayers	Unique electronic and superconducting performance	Synthesis of individual layers and their 2D structural retaining during processing	Graphene, MXene, black phosphorus	

Note: 0D, zero-dimensional; 1D, one-dimensional; 2D, two-dimensional

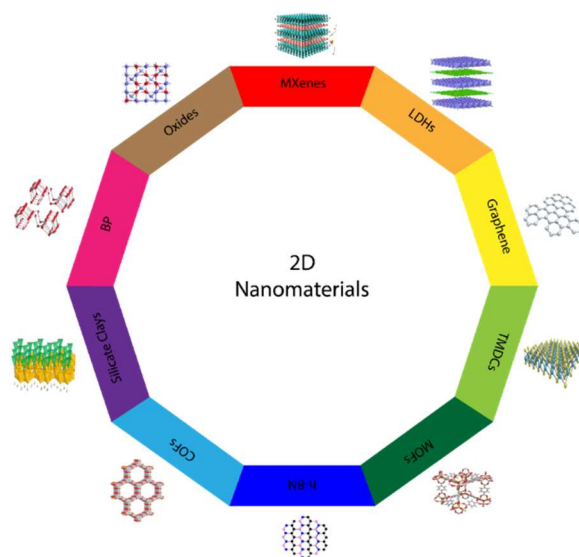


Figure 1. Schematic illustration showcasing most common members of the two-dimensional (2D) materials family as follows: a) MXenes², b) layered double hydroxides (LDHs)³, c) graphene, d) transition metal dichalcogenides (TMDCs), e) metal-organic frameworks (MOFs), f) hexagonal boron nitride (h-BN)⁴, g) covalent-organic frameworks (COFs)⁵, h) silicate clays⁶, i) black phosphorus⁷, j) oxides.⁸

1 H Hydrogen nonmetal																	2 He Helium noble gas
3 Li Lithium alkali metal	4 Be Beryllium alkaline earth metal											5 B Boron metalloid	6 C Carbon nonmetal	7 N Nitrogen nonmetal	8 O Oxygen nonmetal	9 F Fluorine halogen	10 Ne Neon noble gas
11 Na Sodium alkali metal	12 Mg Magnesium alkaline earth metal											13 Al Aluminum metal	14 Si Silicon metalloid	15 P Phosphorus nonmetal	16 S Sulfur nonmetal	17 Cl Chlorine halogen	18 Ar Argon noble gas
19 K Potassium alkali metal	20 Ca Calcium alkaline earth metal	21 Sc Scandium transition metal	22 Ti Titanium transition metal	23 V Vanadium transition metal	24 Cr Chromium transition metal	25 Mn Manganese transition metal	26 Fe Iron transition metal	27 Co Cobalt transition metal	28 Ni Nickel transition metal	29 Cu Copper transition metal	30 Zn Zinc transition metal	31 Ga Gallium metal	32 Ge Germanium metalloid	33 As Arsenic metalloid	34 Se Selenium nonmetal	35 Br Bromine halogen	36 Kr Krypton noble gas
37 Rb Rubidium alkali metal	38 Sr Strontium alkaline earth metal	39 Y Yttrium transition metal	40 Zr Zirconium transition metal	41 Nb Niobium transition metal	42 Mo Molybdenum transition metal	43 Tc Technetium transition metal	44 Ru Ruthenium transition metal	45 Rh Rhodium transition metal	46 Pd Palladium transition metal	47 Ag Silver transition metal	48 Cd Cadmium transition metal	49 In Indium metal	50 Sn Tin metal	51 Sb Antimony metalloid	52 Te Tellurium metalloid	53 I Iodine halogen	54 Xe Xenon noble gas
55 Cs Cesium alkali metal	56 Ba Barium alkaline earth metal	57 La Lanthanum lanthanide	58 Ce Cerium lanthanide	59 Pr Praseodymium lanthanide	60 Nd Neodymium lanthanide	61 Pm Promethium lanthanide	62 Sm Samarium lanthanide	63 Eu Europium lanthanide	64 Gd Gadolinium lanthanide	65 Tb Terbium lanthanide	66 Dy Dysprosium lanthanide	67 Ho Holmium lanthanide	68 Er Erbium lanthanide	69 Tm Thulium lanthanide	70 Yb Ytterbium lanthanide	71 Lu Lutetium lanthanide	
87 Fr Francium alkali metal	88 Ra Radium alkaline earth metal	89 Ac Actinium actinide	90 Th Thorium actinide	91 Pa Protactinium actinide	92 U Uranium actinide	93 Np Neptunium actinide	94 Pu Plutonium actinide	95 Am Americium actinide	96 Cm Curium actinide	97 Bk Berkelium actinide	98 Cf Californium actinide	99 Es Einsteinium actinide	100 Fm Fermium actinide	101 Md Mendelevium actinide	102 No Nobelium actinide	103 Lr Lawrencium actinide	

● M group element present in both MAX and MXene

▲ M group element present in only MAX

✖ A group element

■ X group element

★ Surface Terminations

- M group element present in both MAX and MXene
- ▲ M group element present in only MAX
- A group element
- X group element
- ★ Surface Terminations

Figure 2. Elemental constituents of the MAX phase with basic symbols used to distinguish between different components.⁹

Furthermore, a few properties have set MXenes apart from other family members and are highlighted below. First, various compositions and structures can be formed in MXenes, leading to a rapidly growing group.^{1,43} For example, the MXene family has seen a group of carbides, nitrides, and carbonitrides (e.g., Ti, V, Cr, Y, Zr, Nb, Mo, Hf, Ta, W-based, **Figure 2**). Second, the space between the MXene sheets is also highly versatile and amenable to a host of compounds and cations (e.g., Li, Na, K, Rb, Cs, Mg, Ca, Sr, Ba, and others, **Figure 2**). This allows the layered MXene to be intercalated with various organic molecules and used as exfoliated layer reinforcements in matrix materials (e.g., polymers).⁹ Last but not least, synthesized MXenes also display unique properties of being simultaneously electronically conductive and hydrophilic (e.g., -H, -OH, -F, -Cl, **Figure 2**).⁹

As the syndication of MXenes is a relatively recent discovery and addition to the field of two-dimensional materials, this thesis will focus on MXene synthesis with a demonstration of titanium carbide-based MXene (i.e., Ti_3AlC_2). Specifically, this thesis first summarizes the background and current state of the art in the MAX and MXene synthesis (**Chapter 1**). Second, the synthesis of MAX and MXene will be detailed with characterization results and discussions (**Chapter 2**), followed by their application as surface patterns enabled in 3D printing methods (**Chapter 3**). Finally, the thesis will be concluded with an overview of challenges that need to be overcome in future work (**Chapter 4**).

1.2 Background and Literature Review

1.2.1 MAX Phase

As can be seen in **Figure 3**, the different elements of a MAX phase are usually as follows:¹

- a) M represents an early transition metal (e.g., Ti, V, Cr, Y, Zr, Nb, Mo, Hf, Ta, W)
- b) A is typically a group IIIA or IVA element (e.g., Al, Si, Ge, Sn, S, As, P, In, Ga, Ti, Pb)
- c) X is the termination element (e.g., -O, -F, -OH groups)

Due to the two distinct layers, the MAX phase usually contains a covalent, ionic, or metallic bond in the M-X layers while the M-A bond is weakly bonded.⁶⁸ MAX phases began garnering interest more than twenty years ago when they were spotlighted by Dr. Barsoum.⁶⁹ The family which is comprised of nano-layered ternary carbides and nitrides drew attention due to their unique combination of properties.⁷⁰ These included damage tolerance, low hardness, high strength, structural stability at high temperatures (> 1200 °C), high electrical and thermal conductivity, and machinability comparable to graphite.⁷⁰ Members of this family usually have a structural format of $M_{n+1}AX_n$ where n determines the phase of the material⁷¹. M_2AX , M_3AX_2 , and M_4AX_3 are the most common iterations and are referred to as the 211, 312, and 413 phases. Larger values of n such as 514 and 615 have been reported occasionally.⁷¹ MAX phases are usually synthesized by hot isostatic pressing (HIP), hot pressing (HP), spark plasma sintering (SPS), mechanical alloying (MA), or through self-propagating high-temperature synthesis.^{71,72}

HP and HIP were the methods initially utilized to produce MAX phases.⁷³ The hot pressing method is designed to form a dense compact material which it achieves by creating a high-pressure, high-temperature, and low strain-rate environment.⁷³ Hot isostatic

pressing method is similar with regards to its simultaneous application of high temperature and pressure with the slight change in the type of pressure from uniaxial to isostatic. As a result, the pressure is induced uniformly in all directions with this method.⁷³ To counteract the formation of impurities and attempt the synthesis of monophasic MAX material, Hong et al. utilized spark plasma sintering. The exact nature of the SPS mechanism is still unclear as there have been a few hypotheses.⁷⁴ It was theorized at first that SPS had a thermal diffusion regime that was active for lower temperatures and a volume diffusion method for higher temperatures.⁷⁵ It was then described as a self-adjusting mechanism which was then followed by a sequencing theory.^{76,77}

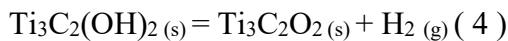
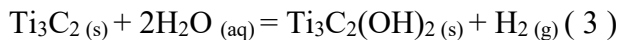
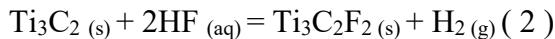
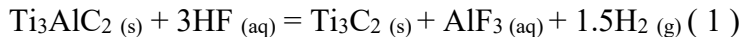
Regardless of its underlying mechanism, SPS eliminates the gaps and forms metallurgical bonds between particles which are the two prerequisites to forming high-density bulk materials.⁷⁴ This method is particularly attractive because the densification of powders can be achieved in relatively milder conditions compared to HP and HIP methods.⁷⁸ In addition, it can be used to consolidate powders that have been synthesized using the self-propagating high-temperature synthesis (SHS) method.⁷⁹ The SHS method involves highly exothermic reactions which once ignited self-propagate throughout the mixture in the form of a combustion wave.⁷⁸ This process is also particularly attractive because no other secondary phases are usually found in the final product. This is a consequence of the self-cleaning nature of this process as impurities are purged away due to the high temperature of combustion.^{79,80}

approach is a top-down approach and is more commonly used due to its cost-efficiency and manufacturing processability. This method involves the exfoliation of the 3D layer counterparts.⁸¹ Specifically, mechanical and chemical exfoliations are two techniques used in the literature for this approach. An example of mechanical exfoliation can be seen using adhesive tape to peel graphene from graphite due to the weak van der Waals force between the layers.⁸¹ However, this is unsuitable for the MAX precursors due to the strong covalent and metallic bonds between the M elements and Al.⁸¹ Chemical exfoliation is the route that is commonly employed when strong bonds between the layers are involved, e.g., when deriving MXenes from their MAX precursor phases.^{1,9,43,45,71,81,82} It is also important to note that before MXene synthesis, it was thought that only weakly bonded three-dimensional solids could be exfoliated.⁸¹ Thus, this research was groundbreaking in the field. During the chemical exfoliation process, the A-element layers must be etched explicitly from $M_{n+1}AX_n$, thus resulting in metal carbides and nitrides with the general chemical formula $M_{n+1}X_n$. As a result of this etching, the functional groups are usually denoted as T_x , which results in $M_{n+1}X_nT_x$. A few etching techniques have been employed in the literature and will be briefly reviewed in **Table 2** and discussed below.

1) HF Etching

HF etching is a top-down approach usually classified under wet etching. The etching process takes advantage of the reaction and elimination of A layers from the precursor MAX phases. Due to the chemical activeness of the weakly bonded layers, selective etching is possible. Simultaneously, the remaining MX layers are terminated with the

surface groups mentioned above. Using one of the more popular titanium carbide precursors ($\text{Ti}_3\text{C}_2\text{T}_x$) as a reference, the possible reactions occur as shown below.^{40,83}



The HF concentration, etching temperature, and etching time are critical parameters that affect the morphology and characteristics of the resulting MXenes.^{81,83} For example, 50 wt.% HF was initially used. Though effective, lower concentrations were optimized due to less HF toxicity (e.g., 5 wt.%). Due to the toxic and corrosive risks involved with the HF etchant, other methods have been developed to prevent direct interaction/contact with HF.⁸³ For example, In Situ HF-Forming Etching Methods usually comprises two species interacting in spontaneous and self-terminating reactions that create the essential HF. This helps prevent direct contact with the etchant.⁸³ The following processes fall under that umbrella and are briefly highlighted.

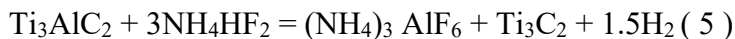
2) Acid/Fluoride Salt Etching

This is the most common two-reactant combination in literature today, which was first reported by Ghidui⁸⁴ in 2014 and involved the etching of Ti_3AlC_2 at 40 °C using an HCL/LiF solution.⁸³ Conductive $\text{Ti}_3\text{C}_2\text{T}_x$ clay was produced using this method, and some of its properties included high plasticity and the ability to be made into a film using Roll-to-Roll pressing.⁸³ Like the HF etching, the HCL/LiF etching process also creates multi-layered MXenes. The process was then further refined, and as it matured, more

configurations of fluorides and acids could be used. Furthermore, the interlayer spacing of the MXenes was directly regulated by the fluoride salts that can alter the layer parameter based on desired properties.⁹ The minimally intensive layer delamination (MILD) method has been preferred among current approaches based on salt etching because single and larger flakes are produced with fewer defects.⁴⁵

3) Bifluoride Salts Etching

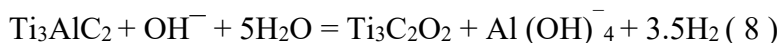
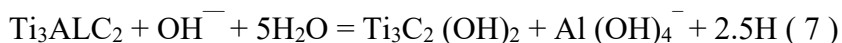
This method was first reported during the etching of epitaxial Ti_3AlC_2 films at room temperature with the application of NH_4HF_2 .⁸⁵ In this process, the hydrated cations from the bifluoride salts are dissociated and adsorbed on the negatively charged surface of the MXenes. This leads to an enlargement of the interlayer spacing, as shown in the following equations.⁸⁵



Since its initial procedures in 2014, the range of bifluoride salt etching has increased from thin epitaxial films to powders. This synthesis process is beneficial when creating MXenes for water-sensitive applications and is preferred due to HF due to its higher operating safety.⁸³ Ti_3AlC_2 is the only precursor etched using this method, with more work being explored to determine the suitability to etch other MAX phases.⁸³ The direct and in-situ HF methods are typically performed at temperatures less than 60 °C, but MXenes can also be obtained at higher temperatures. For example, blending NH_4F with the low eutectic solvent mixed with chlorine chloride and oxalic acid can etch the MAX phase using a hydrothermal process, generating temperatures ranging from 100-180°C.⁸⁶

4) Alkali Etching Methods

The above methods utilize acids as etchants, but low-concentration alkalis can also be used to etch the MAX phase selectively. The main drawback of this method is that only the superficial layer of the precursor is etched, resulting in a meager MXene yield.⁸³ This obstacle can be circumvented if the alkali concentration and temperature increase to a certain threshold. For example, Al was selectively etched from Ti_3AlC_2 using 27.5 M NaOH, resulting in 92 wt.% MXene yield.⁸⁷ During this process, Al follows common pathways by transforming into Al (oxide) hydroxides before dissolution in the alkaline etchant (see reactions below).⁸³



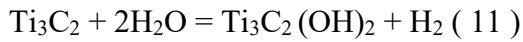
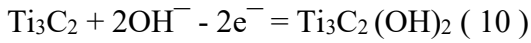
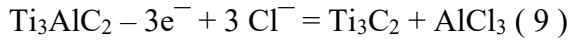
In addition, using concentrated alkali for etching the MAX phase efficiently produces hydrophilic products with F-free terminations.⁸³ However, increasing the scalability of MXene utilizing this method is extremely difficult due to the dangers associated with high-temperature concentrated alkali solutions.⁸³

5) Electrochemical Etching Methods

The preparation of MXenes using this route involves the selective etching away of the Al layer under a specific voltage using its MAX precursor as an electrode.⁸³ The typical voltage used during this technique varies between 0 and 2.5 V, which results in the break in the M-A bond, thus allowing for the successful removal of selective layers.

Consequently, the modulation of the etching voltage and etching time are the main parameters that allow for accurate control and fine-tuning of the etching process⁸³.

Although it has several advantages, the main drawback is a result of the low yield. Plus, this method develops the carbide-derived carbon (CDC) layer, which forms due to the etching process and prevents subsequent etching processes.⁸³ The etching reactions are described below.⁸³



The following processes all classify as molten salt etching methods, which have been explored due to their increased versatility as opposed to the other etching routes, which only etch Al-containing MAX phases. Furthermore, the whole process is exponentially faster than different routes, as the entire manufacturing process can be completed in a matter of hours rather than days⁸⁸.

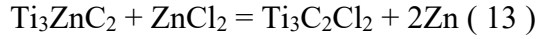
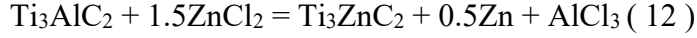
6) Fluoride-Containing Molten Salt Etching Method

As referenced earlier, other etching routes fail to produce MXenes when using non-Al or nitrides MAX phases. As a result, this method is the first choice for synthesizing MXenes with high formation energy.⁸³ The main drawback is the developed terminations, which is why fluorine-free molten salt methods are required.⁸³

7) Fluoride-free Molten Salt Etching Method

In this molten salt etching method, a $\text{ZnCl}_2/\text{NaCl}/\text{KCl}$ molten salt system is under a nitrogen-protected environment.⁸³ In this system, ZnCl_2 was used as the etchant, while stoichiometric quantities of NaCl and KCl in the molar ratio of 1:1 formed the salt bath and reduced the melting point of the eutectic system. The etching process is described in

the equations below.⁸³ As the process is fluoride-free and nonaqueous, the MXene is full of -Cl terminations instead of -F, -O, and -OH.⁸³



8) Other etching processes

These processes include using an alkali-assisted hydrothermal method, which synthesized $\text{Ti}_3\text{C}_2\text{T}_x$ at 270 °C. In addition to this, the first nitride MXene produced, $\text{Ti}_4\text{N}_3\text{T}_x$, was created using a molten salt eutectic mixture of lithium fluoride (LiF), sodium fluoride (NaF), and potassium fluoride (KF) at 550 °C under the flow of argon.⁸¹

Table 2. Summary of MXenes and their synthesis protocols

Methods	MXenes	Precursors	Etchants	Etching Conditions	Surface Termination Groups	Ref.
Direct HF etching methods	$\text{Ti}_3\text{C}_2\text{T}_x$	Ti_3AlC_2	50 wt% HF	RT, 2 h		57
	V_2CT_x	V_2AlC	50 wt% HF	RT, 90 h		
	Nb_2CT_x	Nb_2AlC	50 wt% HF	RT, 90 h		89
	$\text{Nb}_4\text{C}_3\text{T}_x$	Nb_4AlC_3	50 wt% HF	55 °C, 40 h		
	$\text{Ta}_4\text{C}_3\text{T}_x$	Ta_4AlC_3	50 wt% HF	RT, 96 h		90
	Ti_3CNT_x	Ti_3AlCN	50 wt% HF	RT, 72 h		66
	Mo_2C	$\text{Mo}_2\text{Ga}_2\text{C}_2\text{T}_x$	50 wt% HF	RT, 18 h		
	$\text{Hf}_3\text{C}_2\text{T}_x$	$\text{Hf}_3(\text{AlSi})_4\text{C}_6$	50 wt% HF	55 °C, 160 h	-OH, -O, -F	65
	$\text{Zr}_3\text{C}_2\text{T}_x$	$\text{Zr}_3\text{Al}_3\text{C}_5$	50 wt% HF	RT, 60 h		64
	Mo_4VC_4	Mo_4VAIC_4	50 wt% HF	RT, 72 h		91
			50 wt% HF	50 °C, 192 h		63
	$\text{Ti}_3\text{C}_2\text{T}_x$	Ti_3SiC_2	30 wt% HF/35 wt% H_2O_2	40 °C, 45 h 40 °C, 45 h		50

		30 wt% HF/10 ml 1.85 M (NH ₄) ₂ S ₂ O ₈		
		40 ml 30 wt% HF/10 ml 2.5 M K ₂ O ₄	40 °C, 45 h	
		40 ml 30 wt% HF/10 ml 1.25 M FeCl ₃	40 °C, 45 h	
		37.5 ml 20 wt% HF/2.5 ml HNO ₃	RT, 40 h	
In situ HF formation etching	Ti ₂ C ₂ T _x	6 M LiF + 0.9 M HCl	40 °C, 15 h	85
		4 M NaF + 12 M HCl	60 °C, 24 h	
		4 M KF + 12 M HCl	40 °C, 48 h	86
		4 M NH ₄ F + 12 M HCl	40 °C, 48 h	
		2 g FeF ₃ + 6 M HCl	60 °C, 25 h	43
		1 M NaHF ₂	60 °C, 24 h	
	Ti ₃ C ₂ T _x	1 M KHF ₂	60 °C, 24 h	-O,-OH,-F 36
		2 M NH ₄ HF ₂	RT, 24 h	39
		12 M LiF + 9 M HCl	RT, 24 h	
		2 g FeF ₃ + 6 M HCl	60 °C, 50 h	43
		4 M NaF + 12 M HCl	40 °C, 48 h	
		4 M NH ₄ F + 12 M HCl	40 °C, 48 h	34

Alkali Etching	$Ti_3C_2T_x$	Ti_3AlC_2	1 M NaOH + 1 M H_2SO_4	80 °C, 100 h + 80 °C, 2 h	-OH, -O	87
	$Ti_3C_2T_x$	Ti_3AlC_2	27.5 M NaOH	270 °C, 12 h		88
	$Ti_3C_2T_x$	Ti_3AlC_2	1.25 M KOH	180 °C, 24 h		42
Electrochemic al Etching	$Ti_3C_2T_x$	Ti_3AlC_2	1 M NaOH + 0.2 M TMAOH	5 V, 5 h	-OH, -O, - Cl	89
	Ti_2CT_x	Ti_2AlC	2 M HCl 1 M HCl	0.6 V, 120 h 0.3 V, 9 h, 50 °C		90
	Ti_2CT_x	Ti_2AlC	ZnCl ₂	550 °C, 5 h, Ar		91
Molten Salt Etching	Ti_2CT_x	Ti_2AlC	CuCl ₂	650 °C, 24 h, Ar	-O, -Cl	92
	Ti_2CT_x	Ti_2AlC	CdCl ₂	650 °C, 24 h, Ar		
	Ti_2CT_x	Ti_2AlC	FeCl ₂	700 °C, 24 h, Ar		
	$Ti_3C_2T_x$	Ti_3AlC_2	CoCl ₂	650 °C, 24 h, Ar		
	$Ti_3C_2T_x$	Ti_3AlC_2	NiCl ₂	650 °C, 24 h, Ar		
	$Ti_3C_2T_x$	Ti_3AlC_2	I ₂	100 °C		50
Other etching methods	Mo_2C	Mo_2Ga_2C	Ultraviolet light(100W)	3-5 h	-O	93
	$Ti_3C_2T_x$	Ti_3AlC_2	Surface Acoustic waves (SAWs), LiF(≈ 0.05 M)	Millisecon d	-O, -OH, -F	94
	Ti_2CT_x	Ti_2SC	Thermal reduction strategy	400-900 °C, 30 min, Ar/H ₂	-O, -OH	95
	$Ti_2C_2T_x$	Ti_2AlC_2	Algae	RT, 1 day		96

CHAPTER 2

MAX AND MXENE SYNTHESIS

2.1 Materials

Titanium carbide (TiC) (i.e., avg. particle size ~2 mm, 99.5 % purity), aluminum (Al) (i.e., avg. particle size ~325 mesh, 99.5 % purity), and titanium (Ti) (i.e., avg. particle size ~325 mesh, 99.5 % purity) powders were obtained from Alfa Aesar. All materials were purchased and used without further treatment. **Figure 4** shows the flow chart describing the synthesis of MAX and MXene phases, with details explained below.

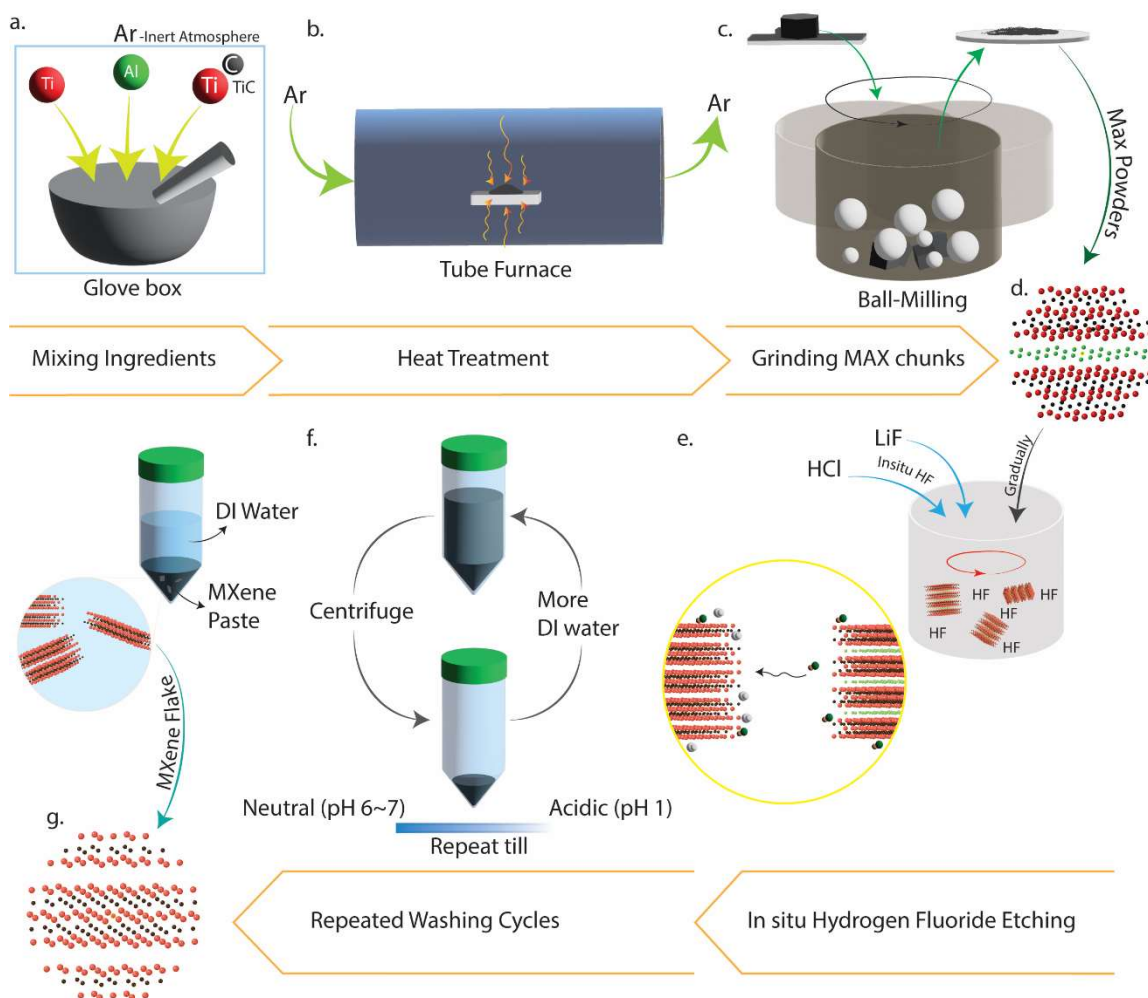


Figure 4. Process flowchart illustrating the experimental steps involved in the synthesis of MXenes from elemental powders of MAX phase to colloidal $\text{Ti}_3\text{C}_2\text{T}_x$ ink solutions.⁹²

2.2 MAX Phase Synthesis

MAX powders were synthesized by mixing TiC, Al, and Ti powders in the molar ratio 2:1.1:1.⁵⁴ The mixing was carried out under an argon-purged environment in a glovebox (VTI Universal, Gloucester, MA, U.S.). This inert atmosphere was used to prevent oxidation during the mixing and grinding. The homogeneous mixture was then transferred to the tube furnace and heated under uniform argon flow in an alumina crucible (**Figure 4b**). It comprised three stages, including the (i) ramp-up stage, where the powders were heated from room temperature to 1350 °C at a constant rate of 5 °C/min, (ii) soaking stage, where a maximum temperature of 1350 °C was held for 2 h, and (iii) cooling stage from 1350 °C to the room temperature. As a result of the sintering, the loosely packed powders agglomerated as hard, chalky flakes that were then ground into fine powders using a planetary ball mill (F-P2000 Focucy High-energy, Changsha, HN, China) (**Figure 4c**). During the milling process, multiple runs of rates greater than 200 rpm were performed for at least 15 min per cycle to ensure that the flakes were reduced to a small-enough size before sieving.

The milled powders were then passed through a 400-mesh sieve to obtain uniformly distributed powders of $\sim 38 \mu\text{m}$ for the particle size.⁵⁴ As a result of these procedures, ~ 0.2 g of the powder was lost between heat treatment and milling, resulting in a 94 % yield for each run.⁵⁴

2.3 MXene Synthesis

During the etchant preparation, 74.7 ml of 12 M HCl was diluted with 100 ml of DI water to form a 9 M HCl solution. Subsequently, LiF powder (0.8 g) was gradually dissolved in 10 ml of 9 M HCl solution under constant magnetic stirring with a rate of 500 rpm for 10 min to form desirable concentrations. Once the acidic solution had entirely dissolved the LiF salt, 0.5 g of MAX phase powder was gradually added to the etchant solution (i.e., HCl/LiF). This addition was done slowly to avoid severe reactions experienced during abrupt MAX addition in etchants.^{45,54} This mixture was then magnetically stirred at 500 rpm for 24 h at 35 °C.

After the delamination procedure, the exfoliated mixture was collected and washed several times to neutralize the acidic pH of the mix. First, DI water was added to the mixture and placed in the centrifuge for washing. Each cycle was performed at 3500 rpm for 10 min. This step was repeated till the pH of the supernatant was ~ 6 . The slurry suspensions were then collected and dispersed in deaerated water. This colloid was then delaminated using sonication via the bath and tip sonicators for 30 min each, with the latter being completed under flowing argon to avoid oxidation. Followed with the centrifugation at a rate of 3500 rpm for 1 h, the stable colloidal supernatant was collected, and vacuum filtered through a PVDF membrane. A thin film was formed on the filtration membrane (**Figure 4**). The flakes were then dispersed in different solvents (e.g., 50 mg mL⁻¹ aqueous DI water, 50 mg mL⁻¹ ethanol, 50 mg mL⁻¹ methanol) and stored at low temperatures to prevent degradation (**Figure 4**).

2.4 Characterizations

Morphological studies of the heat-treated MAX and MXene powders were performed using a Zeiss Auriga high-resolution field emission scanning electron microscopy (SEM). This SEM was coupled with an Everhart-Thornley (E-T) detector to capture EDS images. The resolution was manually operated and optimized to produce high-quality images. The surface structure and characteristics of MAX and MXene powders were confirmed through the SEM images, including the EDS images that exposed the surface terminations of the samples. Topographical studies were carried out using a WiTech Alpha 300 RA atomic force microscope (AFM). Thus, the thickness of the de-sonicated aqueous MXene flakes was quantitatively produced via the tapping mode of the AFM tip. Structure crystallinity and composition were determined using X-Ray Diffraction (XRD) analysis. The quantitative X-ray intensities were captured using a PAN analytical X'Pert PRO powder diffractometer.

2.5 Results and Discussions

The SEM images in **Figure 5** confirmed the fine powder morphology of the synthesized MAX phase. MAX phases are highly dense materials with tightly packed layers, which can be seen from the stacking and cross-sectional views in **Figures 5(b₁-b₂)**. Furthermore, the MAX crystal obtained in **Figure 5a₁** is highly dependent on the elemental precursor materials and heating rates employed during its synthesis.⁹³ The EDS images in **Figures 5(a₂-a₆)** exhibited the chemical composition of elements (e.g., Ti, and C) expected from these powders. Ti, Al, and C are direct results of the elemental powders, while the presence of O suggests that a slight oxidation of the powders may have occurred during mechanical alloying (MA).⁹⁴

The wide-angle X-ray diffraction is an essential technique and one that validated the successful synthesis of both the MAX phase and MXene specimens. The distinct peaks and valleys of the diffraction pattern validated the crystalline structures of both the MAX phase and MXenes. These intensities were labeled by cross-referencing with established patterns in literature.⁹⁵ As can be seen in **Figure 5**, there are ~ ten 312 MAX crystal peaks. These occurred at $2\theta = 9.00^\circ$ (002), 18.59° (004), 33.52° (101), 36.52° (103), 38.30° (104), 41.26° (105), 47.97° (107), 55.91° (109), 55.96° (110), 64.91° (1011). The appearance of these peaks was consistent with the literature albeit with small shifts in the horizontal.⁹⁵ The successful etching of MXene was confirmed with the disappearance of all related Ti_3AlC_2 MAX phase peaks and the distinct changes to the (002)/(004) peaks.⁹⁵

There was a general reduction in the intensities of both peaks and the shift of the 004 peaks from $2\theta = 18.63^\circ$ to 12.95° as can be seen in **Figure 5**. The broadening of the 002 peak is also further confirmation of successful Al removal.⁹⁵ The presence of other peaks outside the first two is not typical of all MXenes. These peaks starting from $2\theta = 34.03^\circ$ (104) to 65.60° (214) are related to TiC and Al_2O_3 and established contaminants of multilayered MXene structures.⁹⁵ Delaminated MXene flakes on the other hand exhibit only the 002 peak usually free of contaminants (e.g., non-etched MAX phases).^{54,96}

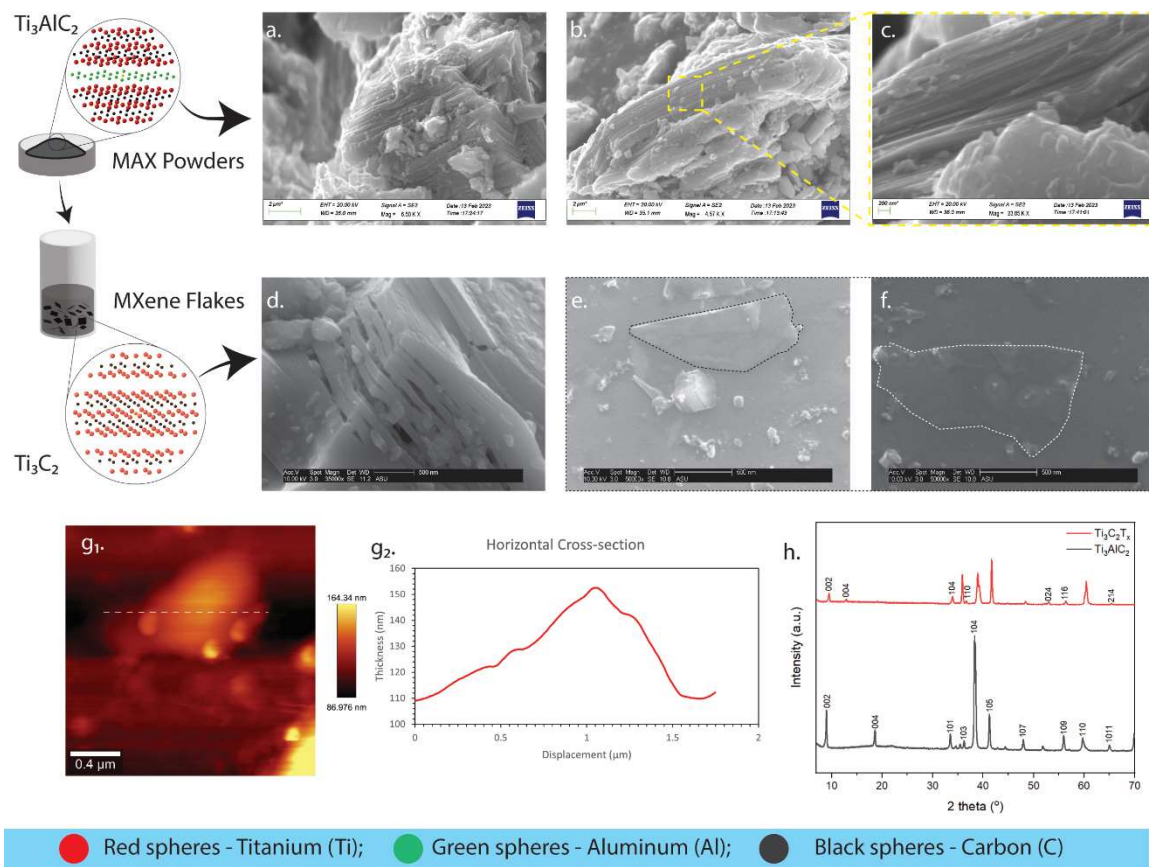


Figure 5. Characterizations of MAX phase and MXene throughout the synthesis process. a.) Frontal SEM micrograph of MAX phase showcasing uniform surface morphology and kink bands, b – c.) Cross-sectional SEM imaging of Ti_3AlC_2 at different resolutions and magnifications, d.) Cross-sectional SEM imaging of multi-layered $\text{Ti}_3\text{C}_2\text{T}_x$ illustrating capacious spacing between layers after etching, e – f.) Delaminated $\text{Ti}_3\text{C}_2\text{T}_x$ sheets at different resolutions, g₁ – g₂.) AFM images depicting cross-sectional thickness of multi-layered $\text{Ti}_3\text{C}_2\text{T}_x$ stack along the horizontal plane, h.) WAXD diffraction patterns of Ti_3AlC_2 before and after etching displaying intensities of MAX phase and resulting MXene at respective phase angles.⁹²

CHAPTER 3

DEMONSTRATIONS OF MXENE APPLICATIONS

3.1 Materials

Feedstock for the printing was prepared by dispersing MXene nanoparticles in deionized (DI) water to form aqueous solutions of different concentrations. Isopropyl alcohol/methylbenzene (IPA/toluene) was employed in a 2.25:1 ratio to form 50 mL of antisolvent solution. 0.5 mL of aqueous MXene dispersions (30, 50, 100, and 200 mg mL⁻¹) is subsequently added to 1.5 mL IPA/toluene solution. The suspension was then centrifuged at 7800 rpm for 10 min and then vacuum dried at standard room temperature ($T \sim 20\text{ }^{\circ}\text{C}$). Ensuing desiccation of the samples, the slurries were then re-dispersed in DI water and sonicated for 8 h to create viscous MXene ink. The feedstock was then loaded into a polypropylene fluid dispensing syringe barrel (10-cc, AHS, USA). Finally, the ink was extruded using a motorized fluid dispensing pump system (KD Scientific LEGATO 200). The pulse rate was set at a constant of 0.075 mL min⁻¹ and extrusion was carried out for ~ 0.25 min per sample.

3.2 Characterizations

The study of the rheological behavior of MXene dispersions played a crucial role in fine-tuning the printability of the ink. The suitability of the printable inks was ascertained after analysis of viscoelastic parameters (i.e., viscosity, storage modulus, loss modulus). Flow and frequency sweep experiments were carried out on a Discovery HR-2 hybrid rheometer (TA Instruments, DE) with an 8 mm parallel plate, ETC Aluminum system (gap = 50 μm , amount ~ 0.25 mL). All viscoelastic parameters were analyzed in the same shear

rate range (i.e., $0.1 - 100 \text{ s}^{-1}$). The syringe was then attached to an open-source 3D printing system (System 30M, Hyrel, USA). With the setup established, the printing was executed by running the designed G-codes. The printing was carried out on a PVA-coated glass slide ($75 * 26 \text{ mm}$). Furthermore, the electrochemical properties of the fabricated MXene ($\text{Ti}_3\text{C}_2\text{T}_x$) were investigated using a three-electrode cell system. $\text{Ti}_3\text{C}_2\text{T}_x$ was allocated the role of the working electrode, Saturated Calomel Electrode (SCE) was employed as the counter electrode, and a platinum wire was utilized as the reference electrode.⁹⁷ Aqueous alkaline 1 M KOH solution was the electrolyte used in the electrochemical tests. The CV measurements were obtained using a Parstat 2273 electrochemical system that ran at several scan rates (i.e., 10, 25, 75, and 100 mV s^{-1}) in a constant potential window (-1 to 1 V).

3.3 Results and Discussions

To achieve stable dispersion quality and nanoparticle homogeneity, $\text{Ti}_3\text{C}_2\text{T}_x$ nanoparticles were suspended in aqueous solutions to form different suspension concentrations (i.e., 30, 50, 100, 200 mg mL^{-1} $\text{Ti}_3\text{C}_2\text{T}_x$ content). Furthermore, **Figure 6a** also shows us that all samples tested experience pseudoplastic (non-Newtonian flow) behavior also characterized as shear thinning (i.e., decreasing viscosity with increasing shear rates). The plots highlight the trend and confirm the relatively low viscosities of the lower $\text{Ti}_3\text{C}_2\text{T}_x$ concentrations (i.e., 30, 50 mg mL^{-1}). Consequently, the ink solutions with higher concentrations of $\text{Ti}_3\text{C}_2\text{T}_x$ (i.e., 100, 200 mg mL^{-1}) were utilized for the direct-ink writing (DIW).

More rheological properties were analyzed to draw more concrete conclusions about the aqueous ink solutions. The storage and loss moduli were studied as functions of the oscillation angular frequency, ω , and these results were plotted in **Figures 6(b-c)**. The storage modulus data were used to determine the amount of energy stored in the elastic structure of the material while the loss modulus data provides information about the amount of energy dissipated from the sample. These two parameters when combined provide useful information about the viscoelasticity of the sample. From **Figures 6(b-c)**, the parameters were stable (i.e., little to no fluctuations) for the angular frequency range investigated (i.e., $10^{-1} - 10^2$ rad s⁻¹). Consequently, this makes the ink solutions adequate candidates for deposition on coated substrates and the creation of free-standing architectures.

The storage and loss modulus values were used to help predict the behavior of the fluid after deposition. Furthermore, the viscoelastic models allowed me to predict the complete transition of the ink solution from elastic to viscous behavior. This change occurred at the critical junction ($G' = G''$) Suitable inks delay this transition as long as possible and are consequently a big factor when selecting the inks used to print the patterns in **Figures 6(d-e)**. Consequently, the main trend observed from **Figures 6(a-c)** was that the viscoelastic parameters grew more favorable as a greater concentration of $\text{Ti}_3\text{C}_2\text{T}_x$ was added to the aqueous solution. On the other hand, a balancing act was required to prevent over-densification of the ink which could potentially result in clogging of the printing nozzle.

After the rheology was complete, the 100 and 200 mg mL⁻¹ aqueous MXene ink solutions were utilized to create both rectilinear and zig-zag patterns in **Figures 6(d-e)**.

The optical images illustrate the improved deposition and uniformity of the high-Ti₃C₂T_x concentration inks as compared to the low-Ti₃C₂T_x concentration ink solutions observed in previous formulations. The electrical properties of deposits on different substrates were then investigated. Circular dots (diameter $\approx$ 9.15 mm) of all four concentrations (i.e., 30, 50, 100, 200 mg mL⁻¹) were dropped on a rough substrate. The resistances of the depositions were collected using the two-point probe technique (KEITHLEY multimeter) and the conductivity values were subsequently measured using the following equation.

$$\sigma = L/RA \quad (14)$$

where L represents the length of the sample (m), R stands for the resistance measured (Ω), A is the cross-sectional area of the sample (m²), and σ is the conductivity. It can be deduced from **Figure 6f** that the conductivity of the depositions is directly proportional to the Ti₃C₂T_x concentration in the solution. Furthermore, the electrochemical properties of the synthesized samples were then observed using a cyclic voltammetric (CV) study. Different scan rates (i.e., 10, 25, 75, and 100 mV s⁻¹) and as can be seen from **Figures 6(g₁-g₂)** the integral area is directly proportional to the scan rates. This paradigm shift indicates a change in potential as the scan rate increases.⁹⁸ The specific capacitance (C_{sp}) of the Ti₃C₂T_x-coated electrode was then calculated from the CV curves using the following equation.⁹⁹

$$C_{sp} = \int(I dV)/vm\Delta V \quad (15)$$

where C_{sp} is the specific capacitance (F g⁻¹), I represents the current (A), $\int(I dV)$ denotes the integral area under the CV curve, v is the scan rate, m is the mass on the electrode of the system, and ΔV is the change in voltage.

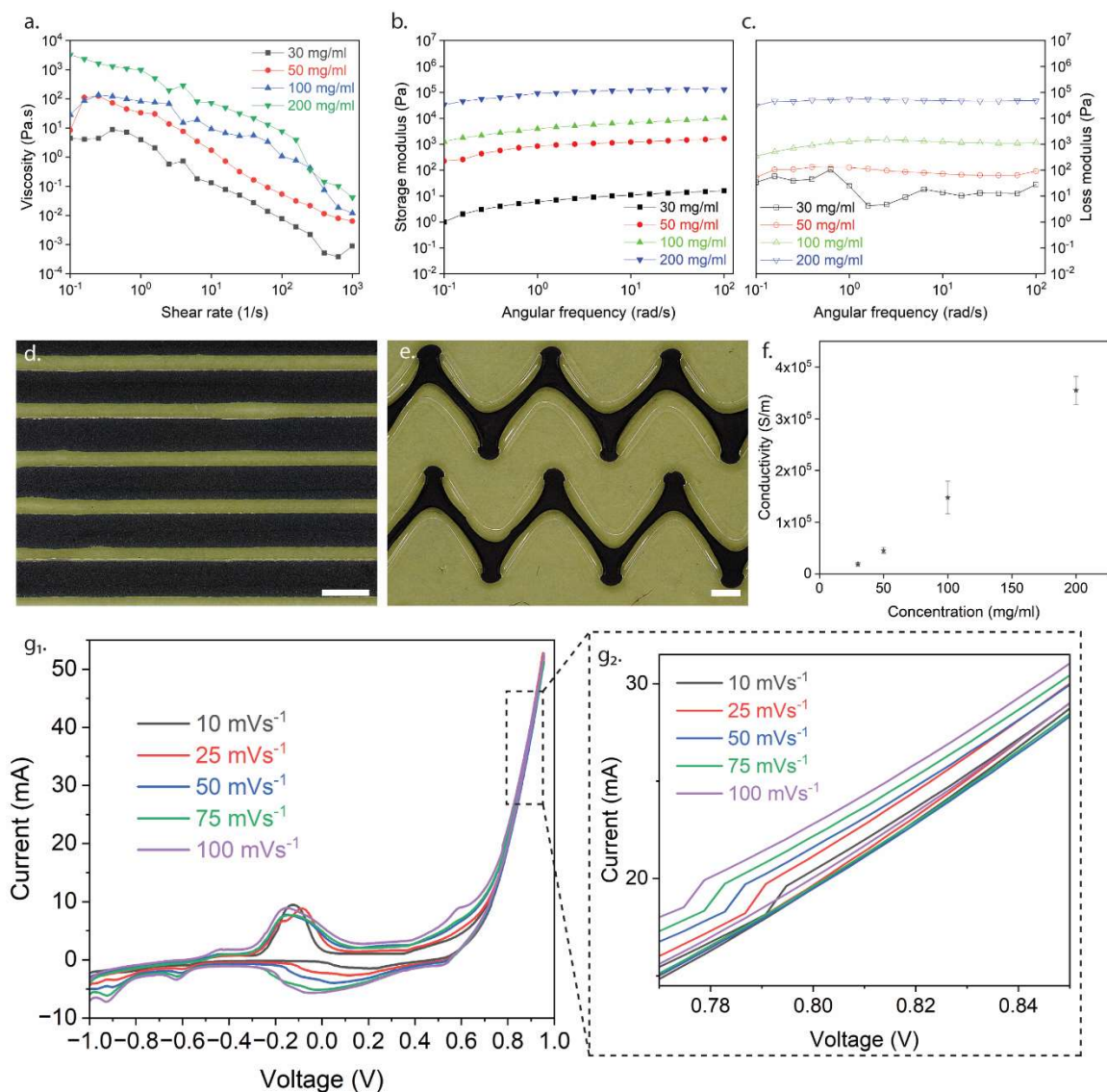


Figure 6. a – c.) Viscoelastic properties of 30, 50, 100, and 200 mg mL⁻¹ aqueous $\text{Ti}_3\text{C}_2\text{T}_x$ ink solutions, d – e.) Printed rectilinear and zig-zag patterns of 100 mg mL⁻¹ $\text{Ti}_3\text{C}_2\text{T}_x$ ink, f.) Conductivity vs concentration chart for aqueous ink solutions, g₁ – g₂.) CV graph highlighting electrochemical properties of $\text{Ti}_3\text{C}_2\text{T}_x$ – coated electrode at multiple scan speeds.⁹²

CHAPTER 4

CONCLUSIONS

This project detailed the synthesis of MXenes from the initial stages to their final deposition forms. Characterizations were then done to analyze their surface morphology, topological features, and their crystal structures via methods of SEM, XRD, AFM, and EDS. Subsequently, these 2D MXene nanoparticles were prepared in polymer inks for 3D printed patterning applications with optimized rheology and printing parameters. This was followed by optical imaging for high-resolution images of the printed patterns.

We have demonstrated the in-house synthesis of MXene and shown its application in 3D-printed patterns and the creation of free-standing architectures. Furthermore, MXenes are highly versatile nanomaterials with massive potential in several industries ranging from wearables due to their flexibility to electromagnetic shield interference in devices. Future work beyond the scope of this project will focus on overcoming issues such as tuning surface functionalities, increasing micropatterning resolutions, and improving the yield of synthesis processes. Finally, we were able to showcase excellent electrical and electrochemical properties which if utilized properly would unlock the vast potential of this modern family and become a valuable asset in the new age.

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